Laser Systems for Semiconductor Industry

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EPIC Online Technology Meeting, 9th of June 2020

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System Solutions for Semiconductor / Electronics Processing

3D-Micromac in a nutshell:

• Founded in 2002

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- Over 170 employees
- Based in Chemnitz, Germany
- Customer application center & contract manufacturing
- Over 500 installations worldwide



Ohmic contact formation microPRO™ XS for OCF

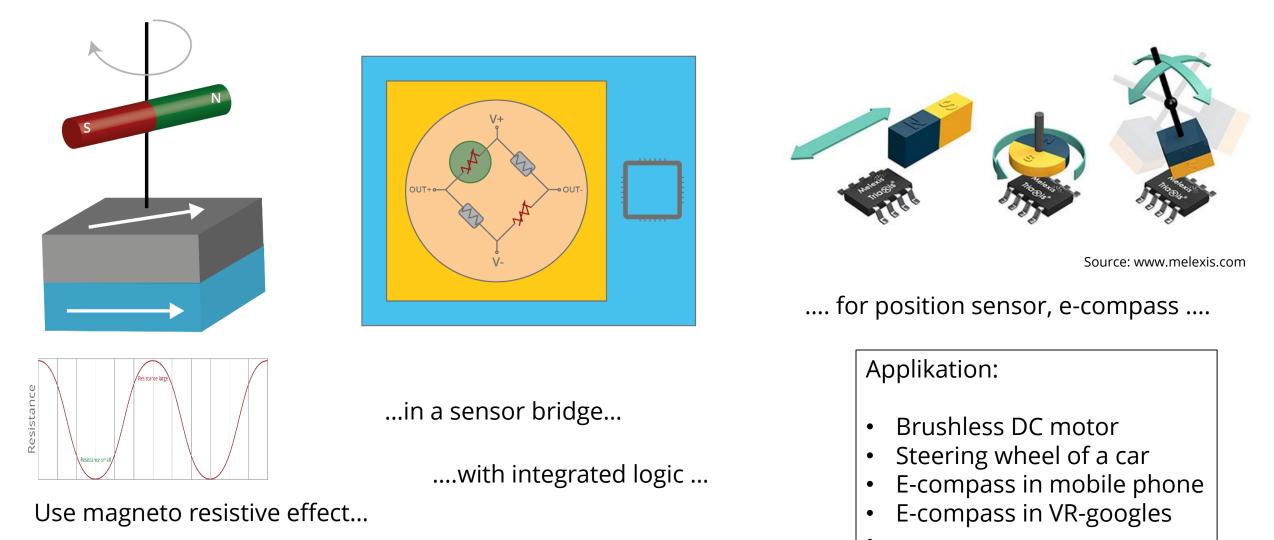


Magnet sensor formation **microVEGA™ xMR**





Motivation for Laser Formation of Integrated Magnet Sensors



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Requirements and Solutions

Requirement

Various sensor size

Product depending position / sensor spacing

Adapt magnetic field strength

Various number of different magnetic orientations

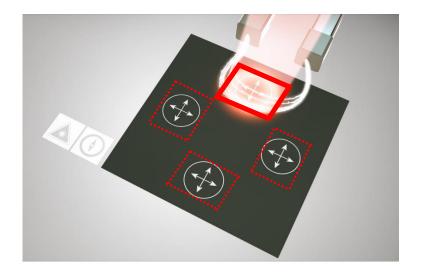
Best sensitivity by homogenous processing

Minimum spacing between sensors

Solution

➔ Motorized aperture

- ➔ Synchronization of laser pulse and motion
- ➔ Variable z-position of laser
- ➔ Freely programmable rotation of magnet unit
- ➔ Usage of modified gauss profile
- ➔ Sharp masking of spot, precise synchronization



Throughput micro VEGA xMR: 520.000 Sensors p.h.! Tool is production approved!



Outlook and Conclusion

Outlook:

- Evaluation of further application
- Improvement of in situ process control
- Increase of throughput:
 - Synchronization motion & laser pulses
 - Stable first pulse / Pulse picking
- Higher pulse energy for larger sensor area



Conclusion: micro VEGA for xMR is a game changing and cost saving solution for integrated monolithic magnet sensor production.



Thank you for your attention!

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